IN THE SPECIFICATION:

Please replace the paragraph beginning at page 7, line 6, with the following rewritten paragraph:

The ninth aspect of the present invention is the transparent electroconductive layered structure according to the eighth aspect, wherein the fine electroconductive oxide particles are of comprise at least one species of material selected from the group consisting of indium oxide, tin oxide and zinc oxide.

Please replace the paragraph beginning at page 9, line 15, with the following rewritten paragraph:

The 19th aspect of the present invention is the method according to the 18th aspect for producing the transparent electroconductive layered structure, wherein the fine electroconductive oxide particles are of comprise at least one species of material selected from the group consisting of indium oxide, tin oxide and zinc oxide.